Supplementary information

Pulsed Laser Deposition of Single-Layer MoS₂ on Au(111): from Nanosized Crystals to Large-Area Films

F. Tumino, C. S. Casari, M. Passoni, V. Russo and A. Li Bassi

Department of Energy, Politecnico di Milano, Piazza Leonardo da Vinci 32, 20133 Milano, Italy
E-mail: francesco.tumino@polimi.it

Our PLD method can produce Single-Layer (SL) MoS2 films over the whole substrate area, of approximately 1 cm². To verify the MoS2 uniformity over the substrate, we performed STM and Raman measurements in different regions of the sample. We will show here the main results of such measurements, with reference to the MoS2 film prepared in a single PLD step (see also fig. 9 in the paper). The same considerations about film uniformity apply also for MoS2 films grown with a multistep PLD approach.

The 200x200 nm² STM images shown in fig. S1 were taken in three different zones of the sample surface: the central region, and two peripheral regions (see the sample scheme in the upper panel of figure S1). The surface morphology shows no significant differences from one region to another: all STM images reveal a uniform SL MoS2 film covering almost completely (> 0.9 ML) the Au surface.

In addition to STM, we acquired Raman spectra on central and peripheral sample regions. The resulting curves are shown in figure S2 and are remarkably similar between each other. These measurements, together with our STM observations, undoubtedly point to the uniformity of our PLD-grown SL MoS2 films over an area of approximately 1 cm².

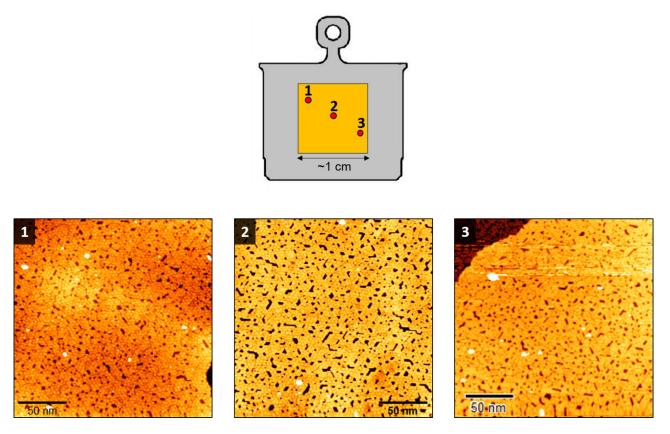


Figure S1: Upper panel: Schematic representation of the sample surface. Labels indicate three different sample regions. Lower panel: 200x200 nm² STM images of SL MoS2 on Au(111) taken on the corresponding sample regions.

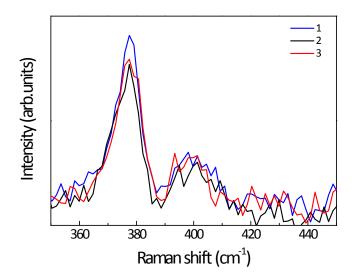


Figure S2: Raman spectra taken on three different sample regions. The curves are labeled according to the sample scheme reported in figure S1.